IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IPF		
In re Patent Application of:)	
Hidekazu MIYAIRI et al. (JUN 0 8 2006 gg))	Group Art Unit: 1722
Serial No. 10/663.671)	Examiner: Hiteshew, Felisa Carla
Filed: September 17, 2003)	
For: LASER APPARATUS, LASER IRRADIATION)	Date: June 8, 2006
METHOD, AND MANUFACTURING METHOD		
OF SEMICONDUCTOR DEVICE		

AMENDMENT

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Office Action mailed March 8, 2006, please consider the amendments and remarks in connection with the above-identified application as follows.